



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. 09/212,726
Filing Date December 15, 1998
Inventor..... Klaus F. Schuegraf
Assignee Micron Technology, Inc.
Group Art Unit..... 2813
Examiner Blum, David S.
Attorney's Docket No. MI22-1098
Title: Semiconductor Processing Methods of Chemical Vapor Depositing SiO₂ on a Substrate

RESPONSE TO DECEMBER 1, 2005 FINAL OFFICE ACTION TO ACCOMPANY RCE FILING

To: Mail Stop RCE
Commissioner for Patents
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AMENDMENTS

Introductory Comments

In reply to the final office action dated December 1, 2005, applicant amends and remarks as follows.